

Fig. 1 (Prior art)

BEST AVAILABLE COPY

## MAILABLE COPY

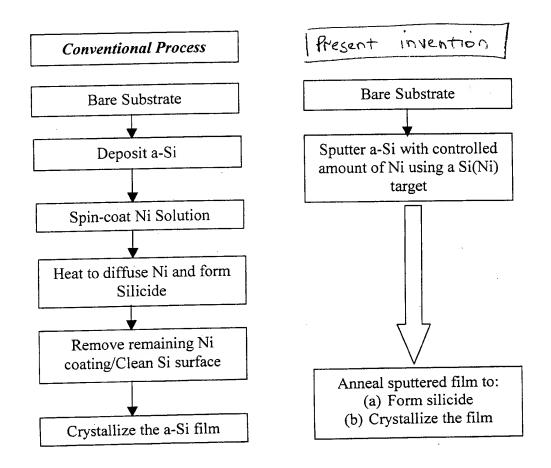
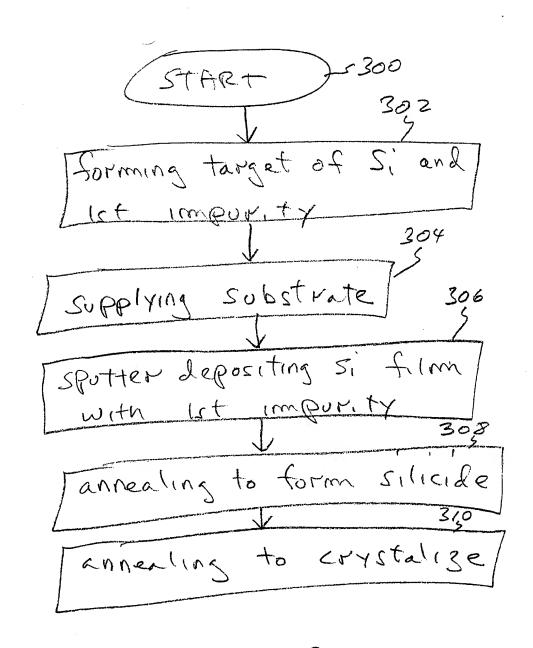


Fig. 2



F.g. 3

Start Supplying Substrate forming target EEST AVAILABLE COPY sputter depositing silicide to form annealing to crystaliz

F19.4